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**AMENDMENTS TO THE SPECIFICATION**

Please replace the paragraph beginning at line 22 on page 14 with the following:

—Fig. 7 illustrates second coating material 220 covering the exposed portions of substrate 210 and patterned first coating 200. In this example, second coating 220 is another positive tone resist. Second coating 220 may be a novolac, TOBC, PMMA, or POS. Although both the first and second coatings may be of the same type, e.g., both novolac or both PBS, they have differing solubilities because at this point only the first coating has been exposed to actinic radiation. Second coating [120] 220 is applied by spin coating a monomer or oligomer suspension or solution in an acidic aqueous or non-polar organic solvent system.—